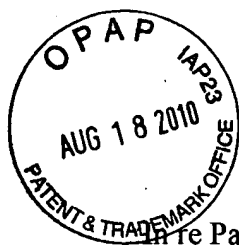


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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Re Patent Application of

CHEVALIER et al

Atty. Ref.: 5215-2; Confirmation No. 7840

Appl. No. 10/557,695

TC/A.U. 1792

Filed: December 22, 2005

Examiner: Alejandro Mulero, Luz L

For: A HIGH DENSITY PLASMA REACTOR

* * * * *

August 16, 2010

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Certificate of Mailing

I hereby certify that this correspondence is being deposited with the US Postal Service as First Class Mail in a postage-paid envelope addressed to the Commissioner for Patents, PO Box 1450, Alexandria, VA 22313-1450 on

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Signed: DB Byers
Duane M. Byers, Reg. No. 33363

Sir:

AMENDMENT

In response to the Office Action dated March 16, 2010, for which a two month extension is requested up to and including August 16, 2010, please amend the application as follows.

The Commissioner is hereby authorized to charge any deficiency, or credit any overpayment, in the fee(s) filed, or asserted to be filed, or which should have been filed herewith (or with any paper hereafter filed in this application by this firm) to our Account No. 14-1140.

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